

WEST Search History

DATE: Monday, March 21, 2005

<u>Hide?</u>	<u>Set Name</u>	<u>Query</u>	<u>Hit Count</u>
<i>DB=EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>			
<input type="checkbox"/>	L27	(substrate or semiconductor or wafer or workpiece) same (clean\$3 or proces\$5 or treat\$3) same (aerosol or snow) same(UV or IR or ultraviolet or infra red or light\$3 or \$3radiat\$5)	28
<i>DB=PGPB,USPT,USOC; PLUR=YES; OP=ADJ</i>			
<input type="checkbox"/>	L26	L25 and l22	20
<input type="checkbox"/>	L25	L24 or l16	10327
<input type="checkbox"/>	L24	134/1,1.3.ccls.	2676
<input type="checkbox"/>	L23	134/1,1.3.ccls,	0
<input type="checkbox"/>	L22	L21 same (UV or IR or ultraviolet or infra red or light\$3 or \$3radiat\$5)	253
<input type="checkbox"/>	L21	(substrate or semiconductor or wafer or workpiece) same (clean\$3 or proces\$5 or treat\$3) same (aerosol or snow)	1681
<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ</i>			
<input type="checkbox"/>	L20	L18 and l16	16
<input type="checkbox"/>	L19	L18 and l16	16
<input type="checkbox"/>	L18	L17 same (UV or IR or ultraviolet or infra red or light\$3 or \$3radiat\$5)	276
<input type="checkbox"/>	L17	(substrate or semiconductor or wafer or workpiece) same (clean\$3 or proces\$5 or treat\$3) same (aerosol or snow)	1935
<input type="checkbox"/>	L16	134/2,7,9,26,30,31,32,34,37;438/906.ccls.	9198
<i>DB=EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ</i>			
<input type="checkbox"/>	L15	2000315672	2
<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>			
(substrate or semiconductor or wafer or workpiece) same (clean\$3 or proces\$5 or treat\$3) same ((aerosol or snow) with (frozen or freez\$3 or pellet\$3 or flak\$3)) same (UV or IR or ultraviolet or infra red)			
<input type="checkbox"/>	L14		6
<input type="checkbox"/>	L13	L12 and ((aerosol with (frozen or freez\$3)) same (UV or IR or ultraviolet or infra red))	1
<input type="checkbox"/>	L12	US-5091068-\$.DID. OR US-4909914-\$.DID. OR US-5125979-\$.DID. OR US-4209028-\$.DID. OR US-5315793-\$.DID. OR US-5613509-\$.DID. OR US-5967156-\$.DID. OR US-5795892-\$.DID.	16
<input type="checkbox"/>	L11	(substrate or semiconductor or wafer or workpiece) same (clean\$3 or proces\$5 or treat\$3) same (aerosol with (frozen or freez\$3)) same (UV or IR or ultraviolet or infra red)	4
<input type="checkbox"/>	L10	((substrate or semiconductor or wafer or workpiece) with (clean\$3 or proces\$5)) same (aerosol with (frozen or freez\$3) with (UV or IR))	0